Docket No.: H0819

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THE INVENTION CLAIMED IS:

- 1. A method for analyzing a semiconductor device comprising: testing a semiconductor device to produce first data and second data; applying a clustering method to the first data to create a clustered first data; and correlating the clustered first data with the second data to determine analyzed data.
- 2. The method of claim 1 wherein the clustering method is spatial signature analysis.
 - 3. The method of claim 1 wherein the clustering method is K-means clustering.
- 4. The method of claim 1 wherein the first data is selected from a group consisting of IV curves and V_t distributions.
 - 5. The method of claim 1 wherein the analyzed data is selected from a group consisting of wafer mapping, commonality, or correlation.
 - 6. A method for analyzing a semiconductor device comprising: testing a semiconductor device to produce physical data and electrical data; applying a clustering method to the electrical data to create clustered electrical data; and
 - correclating the clustered eletrical data with the physical data to determine analyzed data.
- 7. The method of claim 6 wherein the clustering method is spatial signature analysis.
 - 8. The method of claim 6 wherein the clustering method is K-means clustering.
 - 9. The method of claim 6 wherein the process data is selected from a group consisting of IV curves and V_t distributions.
- 10. The method of claim 6 wherein the analyzed data is selected from a group consisting of wafer mapping, commonality, or correlation.
 - 11. Apparatus for analyzing a semiconductor device, comprising: circuitry for testing a semiconductor device, to produce first data and second data; circuitry for applying a clustering method to the first data to create a clustered first data; and

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- circuitry for correlating the clsutered first data with the second data to determine analyzed data.
- 12. The apparatus of claim 11 wherein the clustering method is spatial signature analysis.
- 13. The apparatus of claim 11 wherein the clustering method is K-means clustering.
 - 14. The apparatus of claim 11 wherein the first data is selected from a group consisting of IV curves and V_t distributions:
- 15. The apparatus of claim 11 wherein the analyzed data is selected from a group consisting of wafer mapping, commonality, or correlation.
 - 16. Apparatus for analyzing a semiconductor device, comprising:
 - circuitry for testing a semiconductor device to produce physical data and electrical data;
 - circuitry for applying a clustering method to the electrical data to create clustered electrical data; and
 - circuitry for correclating the clustered eletrical data with the physical data to determine analyzed data.
 - 17. The apparatus of claim 16 wherein the clustering method is spatial signature analysis.
- 20 18. The apparatus of claim 16 wherein the clustering method is K-means clustering.
 - 19. The apparatus of claim 16 wherein the process data is selected from a group consisting of IV curves and V_t distributions.
- 20. The apparatus of claim 16 wherein the analyzed data is selected from a group consisting of wafer mapping, commonality, or correlation.